	Application No.	Applicant(s)	(Ma)
Notice of Allowability	09/686,323	ZHAO, BIN	((***)
	Examiner	Art Unit	
	Hoai v. Pham	2814	
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGORD OF THE NOTICE OF UPON Petition by the applicant. See 37 CFR 1.313	OR REMAINS) CLOSED in or other appropriate commoder GHTS. This application is s	n this application. If not included unication will be mailed in due of	i ourse. <b>THIS</b>
1. This communication is responsive to 11/22/2005.			
2. The allowed claim(s) is/are 118-123.			
<ul> <li>3. Acknowledgment is made of a claim for foreign priority una)</li> <li>All b) Some* c) None of the:</li> <li>1. Certified copies of the priority documents have</li> <li>2. Certified copies of the priority documents have</li> <li>3. Copies of the certified copies of the priority documents</li> </ul>	been received. been received in Application	on No	on from the
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" on noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file ENT of this application.	e a reply complying with the requ	uirements.
4. A SUBSTITUTE OATH OR DECLARATION must be submi INFORMAL PATENT APPLICATION (PTO-152) which give	itted. Note the attached EX es reason(s) why the oath o	AMINER'S AMENDMENT or NO redectaration is deficient.	TICE OF
5. CORRECTED DRAWINGS ( as "replacement sheets") mus	t be submitted.		
(a)  including changes required by the Notice of Draftspers	on's Patent Drawing Revie	w ( PTO-948) attached	
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date			
(b) including changes required by the attached Examiner's Paper No./Mail Date			
Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the	84(c)) should be written on t ne header according to 37 Cl	ne drawings in the front (not the i FR 1.121(d).	заск) от
<ol> <li>DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT I</li> </ol>	SIT OF BIOLOGICAL MAT FOR THE DEPOSIT OF BIO	ERIAL must be submitted. No DLOGICAL MATERIAL.	ote the
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5. ☐ Notice of Ir	nformal Patent Application (PTO	·-152)
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	6. 🗌 Interview S	ummary (PTO-413),	
Information Disclosure Statements (PTO-1449 or PTO/SB/0		/Mail Date Amendment/Comment	
Paper No./Mail Date  4.  Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. ⊠ Examiner's 9. ☐ Other	Statement of Reasons for Allov	vance
		HOA PHA	AM AMINER

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## DETAILED ACTION

## Examiner's amendment

- 1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.
- 2. The application has been amended as follows:

## In the specification:

Page 1, before the first line of the sentence insert --This is a divisional of Application No. 09/193,499 filed November 16, 1998, now U.S. Pat. No. 6,211,561.--.

## Allowable Subject Matter

- 3. Claims 118-123 are allowed.
- 4. The following is an examiner's statement of reasons for allowance: the prior of record fails to disclose the combination of the process steps of manufacturing an interconnect recited in the base claims 118, 120, and 122, including the combination of the process steps of: depositing a sealing layer over said first hard mask to seal said first air gap and said second air gap; depositing a third insulating layer over said sealing layer; forming a via hole through said third insulating layer, said sealing layer, said first hard mask, said second insulating layer, and said first insulating layer.

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5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hoai v. Pham whose telephone number is 571-272-1715. The examiner can normally be reached on M-F.

- 6. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael M. Fahmy can be reached on 571-272-1705. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.
- 7. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

HOAI PHAM PRIMARY EXAMINER